

Form PTO-1449 (Rev. )	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. 13462(36368/123649)	SERIAL NO. 09/883,409
D I P E N T R M E N T O F C I S S <b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  (Use several sheets if necessary)		APPLICANT Markus Gautschi, et al.	
		FILING DATE June 18, 2001	GROUP 1743

## **U.S. PATENT DOCUMENTS**

**RECEIVED**  
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**TC 1700**

## **FOREIGN PATENT DOCUMENTS**

**OTHER DOCUMENTS** (Including Author, Title, Date, Pertinent Pages, Etc.)

Reference Number, Title, Date, Pertinent Pages, Etc.)		
MC	C1	Greene, T.W., <u>Protective Groups in Organic Synthesis</u> , 2nd Edition, 31-34 (1991).
MC	C2	Dixon, D.D., et al., <u>Synlett</u> , 1093-1095 (1998).
MC	C3	Brunckova, J., et al., <u>Tetrahedron</u> , 51, 11945-52 (1995).
MC	C4	Cowper, R.M., et al., <u>Org. Synth. Coll.</u> , 2:480-81 (1943).
MC	C5	Noe, V.C.R., et al., <u>Angew. Chem.</u> , 100:1431-1433 (1988).

**EXAMINER**

M. Gle

**DATE CONSIDERED**

11/04

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**OF PATENTS AND PUBLICATIONS  
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Attorney Docket: 102790-38	Serial No. 09/883,409
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**Applicant:**  
**Gautschi et al.**

Filing Date: June 18, 2001

## **U.S. PATENT DOCUMENTS**

## **FOREIGN PATENT DOCUMENTS**

**OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)**

**MC** A1 B.T. Cho et al.: Tetrahedron: Asymmetry 10 (1999) 1843-1846, "A practical method for synthesis of terminal 1,2-diols in high enantiomeric excess via oxazaborolidine-catalyzed asymmetric reduction"

**EXAMINER:**

*M. Cole*

**DATE CONSIDERED:**

11/04

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